



Preface

This special issue of the *Journal of Photochemistry and Photobiology A: Chemistry* is the *Proceedings for the 3rd Japan-Sino Binational Symposium on Photochemistry*, which was held in Osaka from October 27 to 29, 1994. The third symposium, the chairpersons of which were Professor K. Tokumaru (University of Tsukuba) and Professor Yi Cao (Institute of Photographic Chemistry), followed the first one in Tokyo, Japan in November, 1988 and the second in Beijing, China in September, 1991.

The aim of the symposium is to bring together scientists from the two countries, to promote fruitful scientific discussion on all aspects of photochemistry, and to deepen friendly relations. A few scientists from other East Asian countries were also invited to speak at the third symposium, which covered a wide field of photochemistry, including 28 oral presentations and 77 poster presentations.

We hope that this Proceedings will encourage further international collaboration in the field of photochemistry.

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